

Form PTO-1449  <b>LIST OF PATENTS AND PUBLICATIONS FOR APPLICANT'S INFORMATION DISCLOSURE STATEMENT</b>  (Us several sheets if necessary)	<b>ATTORNEY DOCKET NO.</b> 10003976-4	<b>SERIAL NO.</b> TBA
	<b>APPLICANT</b> Moll et al.	
	<b>FILING DATE</b> TBA	<b>GROUP</b> TBA

REFERENCE DESIGNATION		U.S. PATENT DOCUMENTS		
EXAMINER INITIAL		DOCUMENT NUMBER	DATE	NAME
DF	AA	6,388,307	05/14/02	Kondo et al.
DF	AB	2002/0027232 A1	03/07/02	Shigematsu et al.
DF	AC	6,339,233	01/15/02	Lell
DF	AD	6,316,795	11/13/01	Croke, III
DF	AE	6,251,738	06/26/01	Huang
DF	AF	5,387,808	02/07/95	Nozu
DF	AG	5,349,201	09/20/94	Stanchina et al.
DF	AH	4,821,082	04/11/89	Frank et al.

FOREIGN PATENT DOCUMENTS					
		DOCUMENT NUMBER	DATE	NAME	TRANSLATION YES NO
DF	BA	EPO-0571994A2	05/27/93	Stanchina, William E.	X
DF	BB	JP-6-224230	08/12/94	Yashiki et al.	X
DF	BC	WO 01/09957 A1	02/08/01	Micovic, Miroslav	X

OTHER REFERENCES (Including Author, Title, Date, Pertinent Pages, etc.)		
DF	CA	Bell Telephone Laboratories, Inc., Semiconductor Device, Physics and Technology, S.M. SZE, AT&T Bell Laboratories, 1985, (267-269)
DF	CB	G.J. Sullivan, et al., MBE Growth and Characterization of High Gain AlGaAs/GaAsSb/GaAs NpN HBTs, <i>Inst. Phys. Conf. Ser. No. 120: Chapter 13, 1991 (647-650)</i>
DF	CC	N. Matine, et al., Electrical Stress Damage Reversed in Non-Passivated Fully Self-Aligned InP HBTs By Ozone Surface Treatment, <i>Electronics Letters, December 9, 1999, Vol. 35, No. 25</i>
DF	CD	C.R. Bolognesi, et al., High Performance InP/GaAsSb/InP DHBTs With Heavily Doped Base Layers, <i>2000 IEEE, (12-18)</i>
DF	CE	S.P. Watkins, et al., Heavily Carbon-Doped GaAsSb Grown on InP For HBT Applications, <i>Journal of Crystal Growth 221 (2000) (59-65)</i>
DF	CF	M.W. Dvorak, et al. Abrupt Junction InP/GaAsSb/InP Double Heterojunction Bipolar Transistors With $f_t$ as High As 250 GHz and $BV_{CEO} > 6V$ , <i>2000 IEEE (178-181)</i>
DF	CG	Tohru Oka, et al. Low Turn-on Voltage GaAs Heterojunction Bipolar Transistors With a Pseudomorphic GaAsSb Base, <i>Applied Physics Letters, Vol 78, No. 4, 2001, (483485)</i>
DF	CH	M.W. Dvorak, et al., MOCVD-Grown 175 GHz InP/GaAsSb <sub>1-x</sub> /InP DHBTs With High Current Gains Using Strained and Heavily C-Doped Base Layers
EXAMINER		DATE CONSIDERED
<i>[Signature]</i>		11/21/05

\* Copies of these references are not enclosed Pursuant to 37 CFR 1.98(d). (See accompanying IDS)